

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

S.S. bur
#11/9
2-19-03

In re the Application of:

Havemann et al. Examiner: TBD
Serial No: TBD Art Unit: TBD
Filed: 11/01/01 Docket No.: TI-27506
For: INTEGRATED CIRCUIT HAVING A DOPED POROUS DIELECTRIC AND
METHOD OF MANUFACTURING THE SAME

PRELIMINARY AMENDMENT

November 1, 2001

Assistant Commissioner for Patents

Washington, DC 20231

Dear Sir:

Please amend the above referenced application as follows:

In the Specification:

Page 1, before line 1, insert -This application claims priority under 35 USC §

9' 119(e)(1) of provisional application numbers 60/251,494 filed 12/05/00--